

## Subject card

Subject name and code	Thin film technologies, PG_00058947								
Field of study	Nanotechnology								
Date of commencement of studies	October 2024		Academic year of realisation of subject			2025/2026			
Education level	first-cycle studies		Subject group			Obligatory subject group in the field of study Subject group related to scientific research in the field of study			
Mode of study	Full-time studies		Mode of delivery			at the university			
Year of study	2		Language of instruction			Polish			
Semester of study	4		ECTS credits			4.0			
Learning profile	general academic profile		Assessment form			exam			
Conducting unit		e of Nanotechnology and Materials Engineering -> Faculty of Applied Physics and Mathematics -> ly Politechniki Gdańskiej							
Name and surname	Subject supervisor		dr hab. inż. Marcin Łapir						
of lecturer (lecturers)	Teachers			1	_				
Lesson types and methods	Lesson type	Lecture	Tutorial	Laboratory	Projec	t	Seminar	SUM	
of instruction	Number of study hours	15.0	0.0	30.0	0.0		0.0	45	
	E-learning hours included: 0.0								
Learning activity and number of study hours	Learning activity	Participation in didactic classes included in study plan		Participation in consultation hours		Self-study		SUM	
	Number of study hours	45		5.0		50.0		100	
Subject objectives	The aim of the course is to give information with the techniques (both, production and analysis) used in thin-film technology.								
Learning outcomes	Course outcome		Subject outcome			Method of verification			
	[K6_U10] can forecast and assess potential negative biological and ecological effects of producing nanostructures on an industrial scale and their practical application.		The student is able to plan and conduct an experiment, paying particular attention to energy consumption and other environmental aspects.			[SU1] Assessment of task fulfilment [SU3] Assessment of ability to use knowledge gained from the subject [SU4] Assessment of ability to use methods and tools [SU5] Assessment of ability to present the results of task			
	[K6_U06] can accurately present technological and scientific problems, related to the production and application of nanostructures, to specialists in related fields, and initiate and coordinate interdisciplinary cooperation.		The student knows the techniques of manufacturing and analyzing thin films. Has the necessary theoretical knowledge and uses professional terminology			[SU1] Assessment of task fulfilment [SU2] Assessment of ability to analyse information			
	[K6_W05] has knowledge of inorganic and organic chemistry, physical chemistry and chemical thermodynamics.		problems related to thin films			[SW1] Assessment of factual knowledge [SW3] Assessment of knowledge contained in written work and projects			

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Subject contents	1. Nanothermodynamics, 2. Manufacturing of the thin films, 3. Properties, 4. Analysis of the thin films, 5. Applications, Laboratory:					
	Planning the experiment and deposition of thin metallic films using two PVD methods and an oxide layer using the CVD method. Measurement of their mechanical and optical properties.					
Prerequisites and co-requisites	Passed the exam in the listed below subjects					
	Technologie Otrzymywania Nanomateriałów  Fizyczne Metody Badań Materiałów  Termodynamika  Krystalografia					
Assessment methods	Subject passing criteria	Passing threshold	Percentage of the final grade			
and criteria	exam	51.0%	60.0%			
	lab report	51.0%	40.0%			
Recommended reading	Basic literature	Books and papers. Like eg.  Krishna Seshan, "Handbook of Thin Film Deposition"				
		Hartmut Frey, "Handbook of Thin Film Technology"  Stine, Keith J. "Materials Processing for Production of Nanostructured Thin Films",				
	Supplementary literature Technological news from journals					
	eResources addresses					
Example issues/ example questions/	Design of a photochromic coating for eyeglass lenses  Examination of the properties of an ultrathin dielectric layer					
tasks being completed	Examination of the properties of an u	ultrathin dielectric layer				
tasks being completed	Examination of the properties of an u					

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